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Atty. Docket No. 30205/39509 - Serial No. 10/722,815

Inventors: Cheol Kyu Bok et al.

Title: Overcoating Composition for Photoresist and Method
for Forming Photoresist Pattern Using the Same

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INCREASE OF EXPOSURE ENERGY →



Fig.1
(Prior Art)

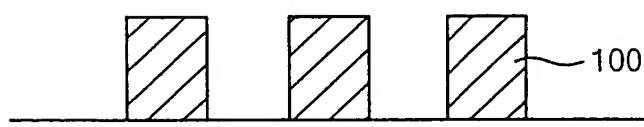


Fig.2a

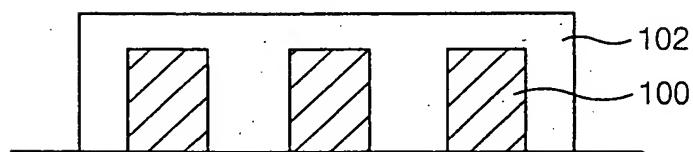


Fig.2b

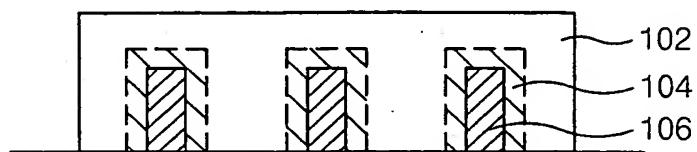


Fig.2c

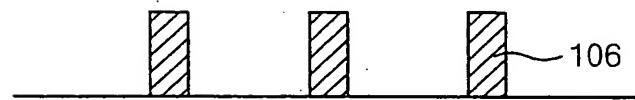


Fig.2d

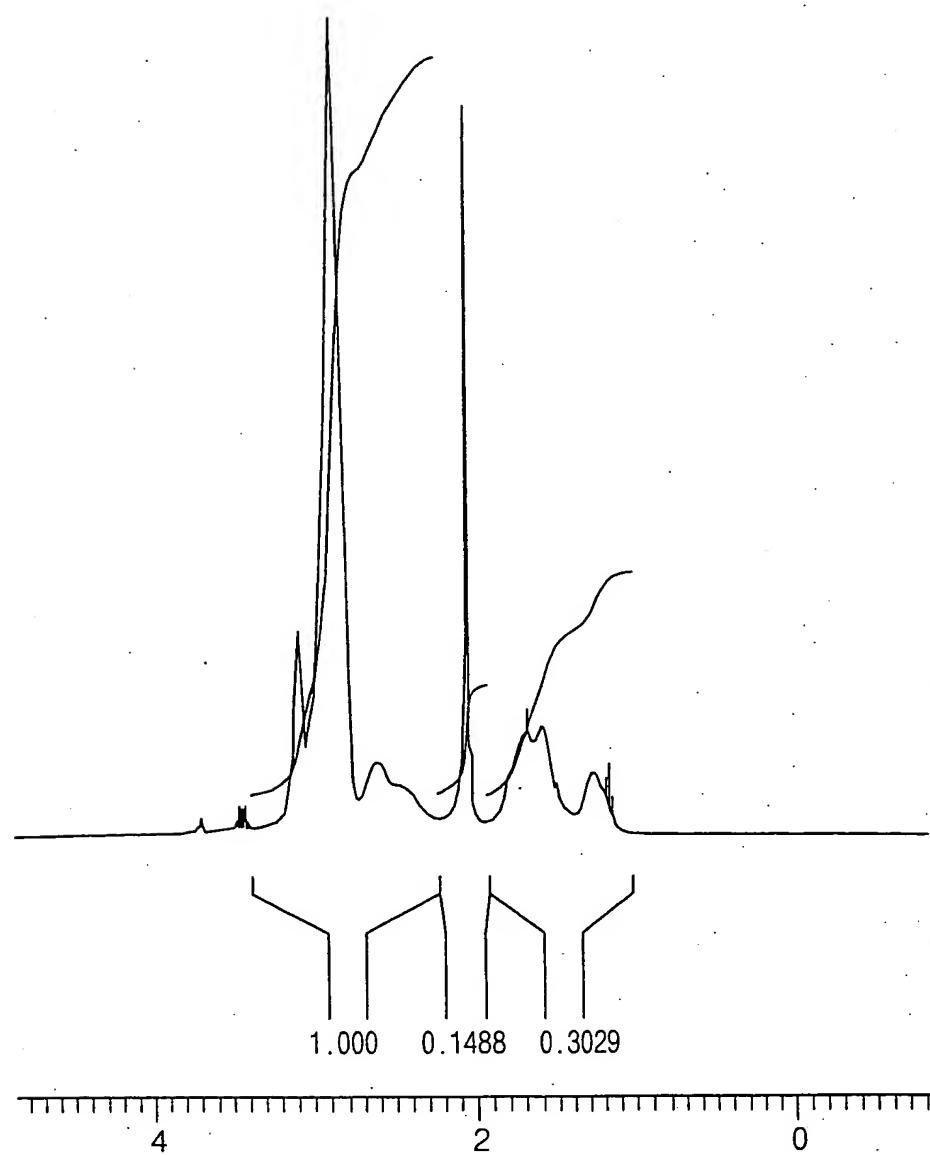


Fig.3

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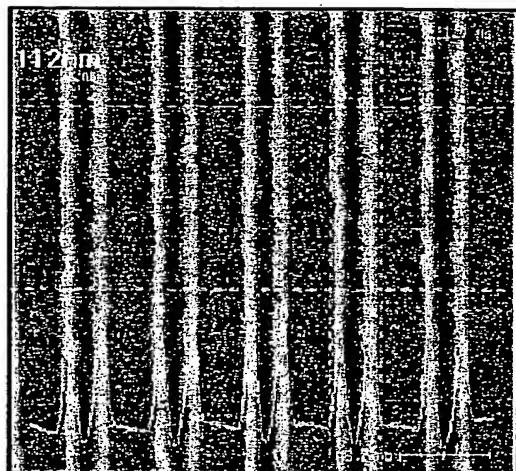


Fig.4a

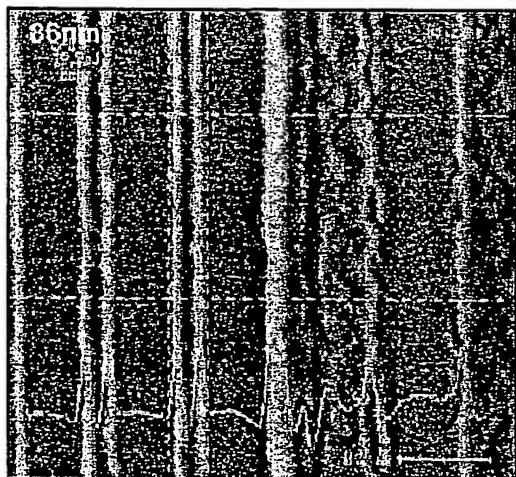


Fig.4b

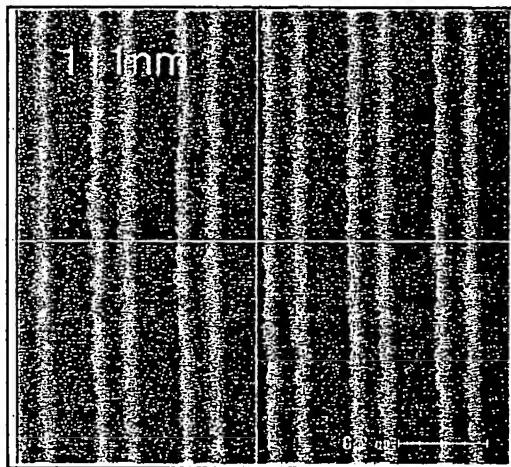


Fig.5a

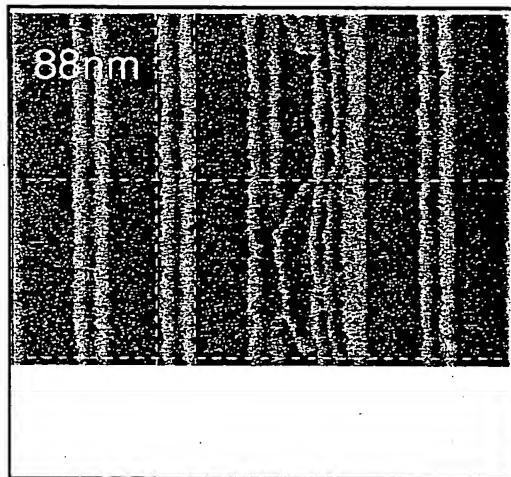


Fig.5b

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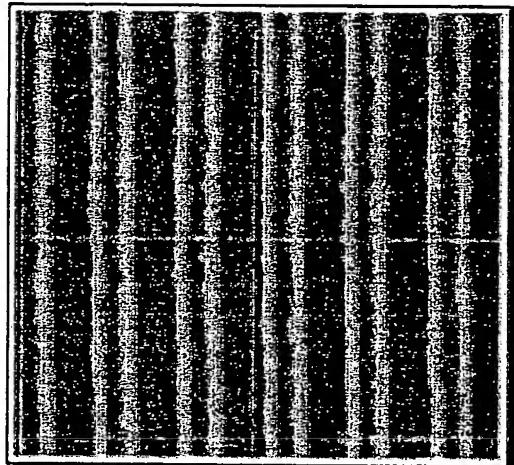


Fig.6a

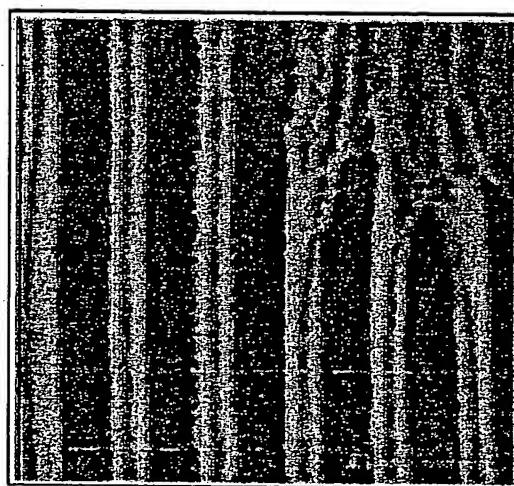


Fig.6b

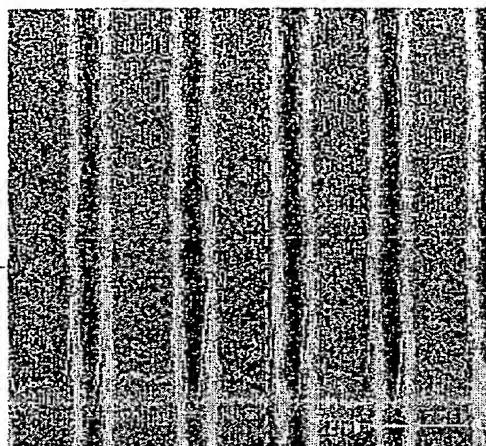


Fig. 7a

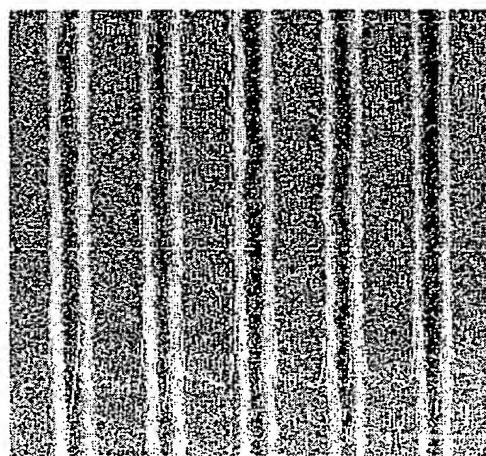


Fig. 7b

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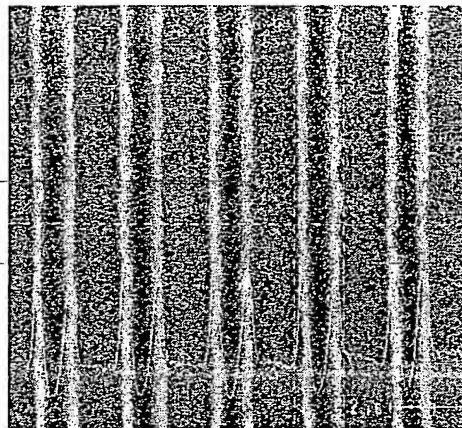


Fig. 8a

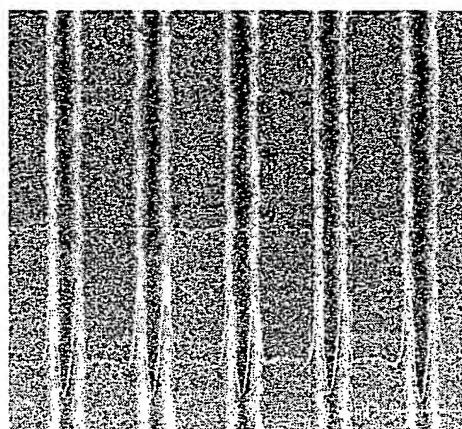


Fig. 8b